

Global Lanthanum Hexaboride (LaB?) Sputtering Target Supply, Demand and Key Producers, 2026-2032

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Abstracts

The global Lanthanum Hexaboride (LaB?) Sputtering Target market size is expected to reach \$ 2482 million by 2032, rising at a market growth of 6.1% CAGR during the forecast period (2026-2032).

In 2025, global sales volume of lanthanum hexaboride (LaB?) sputtering targets reached approximately 420 metric tons, with an average selling price of around \$3.8 million per ton. Total global production capacity for LaB? sputtering targets reached approximately 560 metric tons per year, and the industry's average gross profit margin ranged from 45% to 60%. LaB? sputtering targets are advanced functional thin-film deposition materials made from high-purity LaB? ceramic; they are primarily used in physical vapor deposition (PVD) and magnetron sputtering processes, where ion bombardment of the target surface causes LaB? atoms to deposit and form thin-film layers characterized by low work function, high electron emission performance, excellent thermal stability, and radiation resistance. LaB? materials feature high melting points, strong chemical stability, high electron emission efficiency, and excellent adaptability to vacuum environments. Sputtering targets are typically manufactured using high-purity lanthanum and boron source materials through processes such as powder preparation, mixing and sintering, hot-press densification, machining, and surface treatment. They find primary application in fields including electron beam equipment, vacuum electronic devices, semiconductor manufacturing equipment, display devices, scientific research instruments, and high-end electron emission systems.

Upstream raw materials include high-purity lanthanum metal, high-purity boron powder, rare-earth oxides, ceramic sintering aids, high-purity graphite molds, molybdenum/copper backing plate materials, and precision machining consumables;

high-purity LaB₆ powder, high-purity boron materials, and the sintering/processing stages account for the bulk of material consumption. The midstream sector comprises manufacturers of high-purity sputtering targets, advanced ceramic material companies, and semiconductor material suppliers; these entities utilize processes such as powder preparation, target sintering, crystal structure control, bonding, and quality inspection to supply semiconductor equipment manufacturers, research institutions, electronics manufacturers, and high-end industrial clients. Downstream consumption is concentrated in semiconductor and electronic device manufacturing, electron beam lithography and scientific research equipment, vacuum electronic devices, display and optoelectronic manufacturing, and other high-end equipment applications. Driven by advancements in semiconductor manufacturing and electron-beam technology, the upgrading of scientific research instruments, and the growing demand for high-performance electron-emitting materials, the market for lanthanum hexaboride (LaB₆) sputtering targets continues to expand. Future product development will focus on higher purity (4N–5N grades), increased density, larger target dimensions, low-defect crystal structures, and customized target bonding technologies, presenting significant market opportunities in sectors such as advanced semiconductor equipment, quantum research instrumentation, vacuum electronic systems, and high-end optoelectronic equipment. As a low-work-function electron-emitting material, lanthanum hexaboride is widely utilized in electron sources; its excellent vacuum stability and high-temperature performance make it a key material for high-end electron emission systems.

Lanthanum hexaboride (LaB₆) sputtering targets are a specialized, high-end product within the category of high-performance functional ceramic materials, characterized by high purity, significant technical barriers to entry, and small-batch customization. Due to properties such as low work function, high melting point, excellent electron emission capabilities, and superior vacuum stability, LaB₆ has traditionally been used in electron emission cathodes, electron beam equipment, and high-end vacuum electronic systems. With the advancement of thin-film deposition technologies, the value of LaB₆ ceramic targets is increasingly recognized in the preparation of specialized functional films, high-end electronic devices, and scientific research equipment. High-purity, high-performance sputtering targets demand strict standards regarding purity, density, grain structure, microstructural uniformity, and defect control; consequently, LaB₆ targets entail higher technical thresholds and longer certification cycles compared to conventional metal targets.

From a demand perspective, market growth for LaB₆ sputtering targets is primarily driven by the upgrading of semiconductor equipment and scientific instruments,

advancements in high-tech electronics manufacturing, and an increasing need for high-performance electron emission materials. As semiconductor manufacturing evolves toward higher precision and more complex architectures, the industry's demand for high-purity materials and highly reliable thin-film deposition materials continues to rise, pushing specialized ceramic targets toward higher purity, fewer defects, and more stable sputtering performance. Although the overall market size for LaB₆ targets is smaller than that of mainstream targets—such as those made of aluminum, copper, titanium, or ITO—their unique, irreplaceable role in specialized electron emission applications results in high product value-add and strong customer loyalty.

Regarding technological trends, future competition in the LaB₆ sputtering target sector will focus on the preparation of ultra-high-purity powders, high-density sintering techniques, the manufacture of large-format targets, microstructural control, and the improvement of target utilization rates. The industry currently faces challenges stemming from the fact that LaB₆ is a difficult-to-process ceramic material, requiring precise control over powder particle size, sintering atmospheres, and impurity levels, as well as high machining accuracy. As advanced manufacturing processes—such as powder metallurgy, Spark Plasma Sintering (SPS), and Hot Isostatic Pressing (HIP)—mature, high-performance LaB₆ targets are expected to achieve further improvements in density, uniformity, and sputtering stability, thereby meeting the demands of a wider range of high-end manufacturing applications. From an industry chain perspective, the value of the lanthanum hexaboride (LaB₆) sputtering target sector is concentrated in three key stages: the upstream production of high-purity rare-earth materials and boride powders; midstream target processing and bonding technologies; and downstream applications in high-end electronics manufacturing. Upstream raw material purity and supply stability directly determine the performance of the final targets; midstream enterprises require capabilities in ceramic material R&D, precision processing, and quality testing; while downstream customers prioritize batch consistency, long-term supply stability, and equipment compatibility. Future industry competition will not center merely on capacity expansion but will increasingly focus on material system optimization, customer certification capabilities, and the quality of customized services.

Regionally, the Asia-Pacific market is expected to be a key driver of demand growth for LaB₆ sputtering targets, fueled by the expansion of the semiconductor manufacturing supply chain, the relocation of electronics production capacity, and rising demand for the domestic production of high-end materials. Meanwhile, North American and European markets will maintain steady demand driven by advanced research institutions, the aerospace electronics sector, and the high-end semiconductor

equipment industry. The global supply landscape may evolve toward a multi-regional footprint, giving a competitive edge to enterprises that possess independent high-purity material supply capabilities and stable manufacturing processes.

Overall, the LaB₆ sputtering target sector represents a "niche, high-value, high-barrier" segment of the advanced materials industry. Future development will focus on achieving higher purity, larger sizes, domestic substitution, and expanded application areas. While LaB₆ sputtering targets are unlikely to evolve into a mass-market commodity, their unique physical properties offer significant growth potential in high-end electronics manufacturing and scientific research applications, driven by advancements in semiconductors, electron-beam technology, research equipment, and next-generation electronic systems.

Report Scope

This report studies the global Lanthanum Hexaboride (LaB₆) Sputtering Target production, demand, key manufacturers, and key regions.

This report is a detailed and comprehensive analysis of the world market for Lanthanum Hexaboride (LaB₆) Sputtering Target and provides market size (US\$ million) and Year-over-Year (YoY) Growth, considering 2025 as the base year. This report explores demand trends and competition, as well as details the characteristics of Lanthanum Hexaboride (LaB₆) Sputtering Target that contribute to its increasing demand across many markets.

Highlights and key features of the study

Global Lanthanum Hexaboride (LaB₆) Sputtering Target total production and demand, 2021-2032, (Tons)

Global Lanthanum Hexaboride (LaB₆) Sputtering Target total production value, 2021-2032, (USD Million)

Global Lanthanum Hexaboride (LaB₆) Sputtering Target production by region & country, production, value, CAGR, 2021-2032, (USD Million) & (Tons), (based on production site)

Global Lanthanum Hexaboride (LaB?) Sputtering Target consumption by region & country, CAGR, 2021-2032 & (Tons)

U.S. VS China: Lanthanum Hexaboride (LaB?) Sputtering Target domestic production, consumption, key domestic manufacturers and share

Global Lanthanum Hexaboride (LaB?) Sputtering Target production by manufacturer, production, price, value and market share 2021-2026, (USD Million) & (Tons)

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Global Lanthanum Hexaboride (LaB?) Sputtering Target production by Application, production, value, CAGR, 2021-2032, (USD Million) & (Tons)

This report profiles key players in the global Lanthanum Hexaboride (LaB?) Sputtering Target market based on the following parameters - company overview, production, value, price, gross margin, product portfolio, geographical presence, and key developments. Key companies covered as a part of this study include AEM Deposition, Kurt J. Lesker, Edgetech Industries, JX Nippon Mining & Metals, FUSHI, YEONJIN S-Tech, Stanford Materials, XINKANG, etc.

This report also provides key insights about market drivers, restraints, opportunities, new product launches or approvals.

Stakeholders would have ease in decision-making through various strategy matrices used in analyzing the World Lanthanum Hexaboride (LaB?) Sputtering Target market

Detailed Segmentation:

Each section contains quantitative market data including market by value (US\$ Millions), volume (production, consumption) & (Tons) and average price (US\$/Ton) by manufacturer, by Type, and by Application. Data is given for the years 2021-2032 by year with 2025 as the base year, 2026 as the estimate year, and 2027-2032 as the forecast year.

Global Lanthanum Hexaboride (LaB?) Sputtering Target Market, By Region:

United States

China

Europe

Japan

South Korea

ASEAN

India

Rest of World

Market Segmentation

Global Lanthanum Hexaboride (LaB?) Sputtering Target Market, Segmentation by Type:

Purity: 99.9%

Purity: 99.99%

Purity: 99.999%

Global Lanthanum Hexaboride (LaB?) Sputtering Target Market, Segmentation by Manufacturing Process:

Hot-pressed Sintered LaB? Target

Pressureless Sintered LaB? Target

Spark Plasma Sintered (SPS) LaB₆ Target

Hot Isostatically Pressed (HIP) LaB₆ Target

Global Lanthanum Hexaboride (LaB₆) Sputtering Target Market, Segmentation by Grain Size:

Grain Size: >20 μ m

Grain Size: 5–20 μ m

Grain Size: <5 μ m

Global Lanthanum Hexaboride (LaB₆) Sputtering Target Market, Segmentation by Application:

Semiconductor

Optics

Electronics

Others

Companies Profiled:

AEM Deposition

Kurt J. Lesker

Edgetech Industries

JX Nippon Mining & Metals

FUSHI

YEONJIN S-Tech

Stanford Materials

XINKANG

Key Questions Answered

1. How big is the global Lanthanum Hexaboride (LaB?) Sputtering Target market?
2. What is the demand of the global Lanthanum Hexaboride (LaB?) Sputtering Target market?
3. What is the year over year growth of the global Lanthanum Hexaboride (LaB?) Sputtering Target market?
4. What is the total value of the global Lanthanum Hexaboride (LaB?) Sputtering Target market?
5. Who are the Major Players in the global Lanthanum Hexaboride (LaB?) Sputtering Target market?
6. What are the growth factors driving the market demand?

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